



# Re-optimised electron IsEM cut/ID efficiencies @ high Pt (MC)

High Pt Egamma meeting

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### Introduction/outline

- IsEM cuts re-optimisation based on 2010 data
  - Tightened :
    - Hadronic leakage, lateral shower shape in 2<sup>nd</sup> sampling (R<sub>n</sub>37), shower width in 2<sup>nd</sup> sampling
    - $\Delta E_{max}$  in sampling 1

loose medium tight

- Relaxed/removed :
  - lower bound of E/p removed -> previously, efficiency dropping @ hight pT
  - Upper bound of E/p relaxed -> previously, efficiency stable w.r.t p<sub>T</sub> but rather low
- All cut values available <u>here</u>
- Updated high pT efficiencies study with new cuts
- Customed E/p upper bound
- Brief look at isolation requirement
- Towards an optimised Z' cutflow

#### **Event selection**

#### Dataset used

group10.phys-sm.mc10\_7TeV.115494.Pythia\_Zprime\_ee.recon.AOD.e670\_s933\_s946\_r1831\_tid243875\_0.WZphys.101222.07.D3PD/

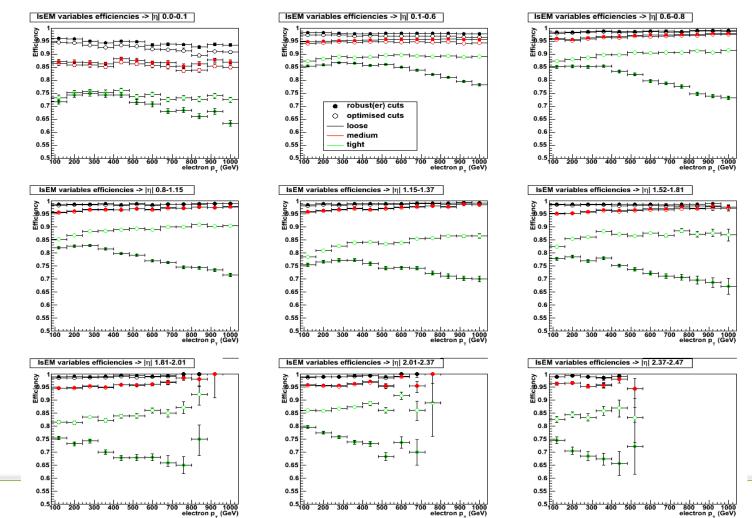
- Preselection :
  - Trigger: L1\_EM14
  - N primary vertex >2
  - el author = 1 or 3
  - |η| < 2.47 + crack region (1.37<|η|<1.52) excluded</li>
  - E<sub>T</sub> cluster >25 GeV
  - Object quality (Otx maps)

Efficiencies are computed from leading and subleading electron passing this preselection.

- Apply is EM ID criteria and determine efficiency vs  $\ensuremath{\mathsf{p}}_{\ensuremath{\mathsf{T}}}$ 
  - $-9|\eta|$  slices reflecting isEM ones for calorimeter variables
  - Loose, medium, tight ID efficiencies quoted w.r.t to preselection
  - IsEM variables efficiencies computed w.r.t preselected electrons passing previous ID (container,loose,medium)
  - all results available on <u>our webpage</u>
  - reported are : changes concerning optimised variables + isolation + E/p optimisation

#### IsEM ID efficiencies - robust vs optimised

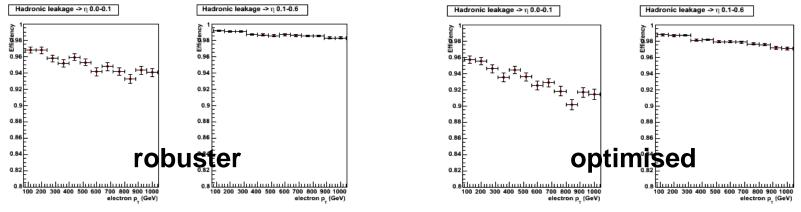
- Loose ID -> lower efficiency for optimised cuts @  $|\eta| = 0-0.1 \& 0.1-0.6$
- Medium -> lower efficiency for optimised cuts @  $|\eta| = 0-0.1 \& 0.1-0.6$
- Tight -> overall improvment with optimised cuts



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## IsEM ID efficiencies - robust vs optimised

- Loose ID -> lower efficiency for optimised @  $|\eta| = 0.0.1 \& 0.1.0.6$ 
  - main reason is tightened hadronic leakage



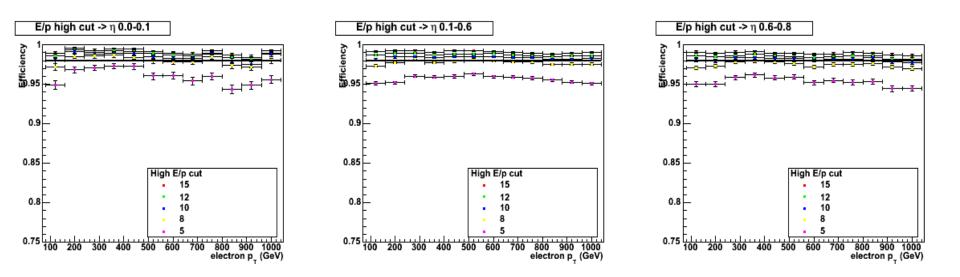
- Other cuts stable
- Loose « unefficiency » coming mafrom hadronic leakage and lateral shower shape in 2<sup>nd</sup> layer
- Medium -> lower efficiency coming from loose cuts (see backup)
  - $\Delta E_{max}$  in sampling 1 cut stable though tightened
- Tight -> overall improvment
  - E/p hight cut changed -> from 5 to 10
  - E/p low cut removed ->previously 0.7
  - -> See details on next slides

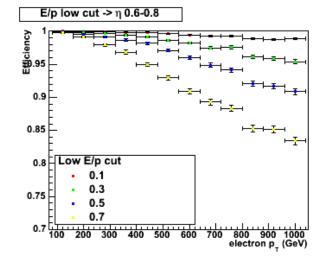
#### Optimised/customed E/p (1)

- Removed E/p lower bound
  - No clear optimisation possible @ high pT
  - Efficiency dropping @ high pT with « loosest » cuts

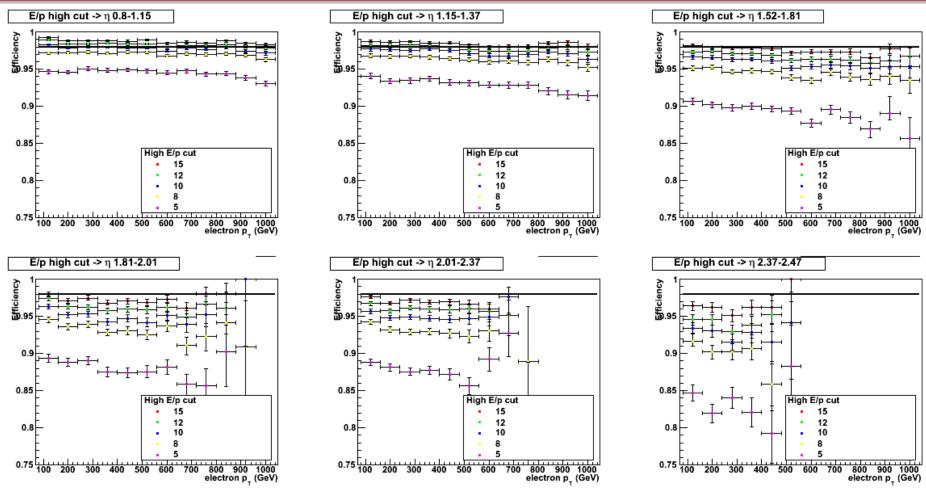
First try of E/p upper bound optimisation

 Baseline -> keep rather constant efficiency w.r.t η bins
 As much independent as possible of η distribution (Z\* / Z')
 Arbitrary choice of 98% efficiency w.r.t medium ID



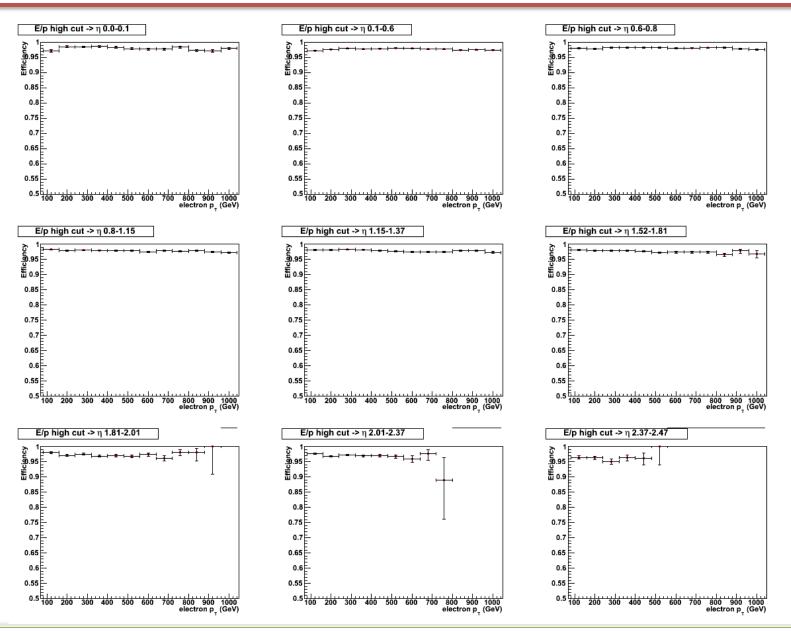


#### Optimised/customed E/p (2)



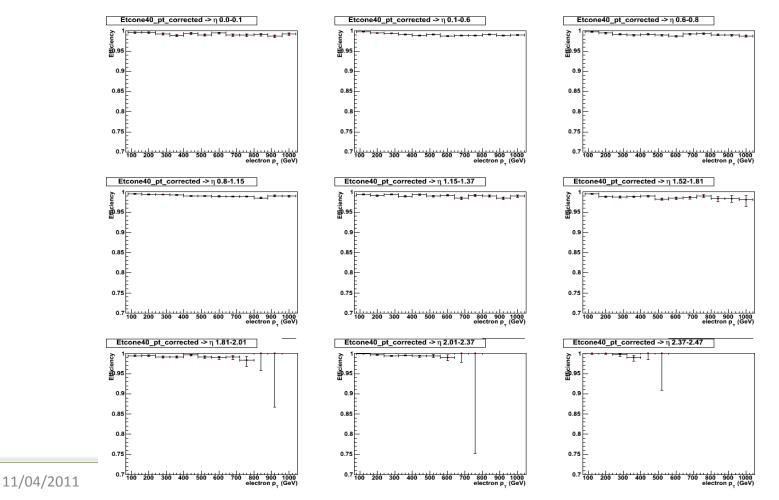
- Efficiency dropping with eta for a fixed cut value
- Defined an optimised set of cuts
  - · [8.0; 8.0; 10.0; 10.0; 12.0; 15.0; 15.0; 15.0; 15.0; 15.0]

#### Optimised/customed E/p (3)



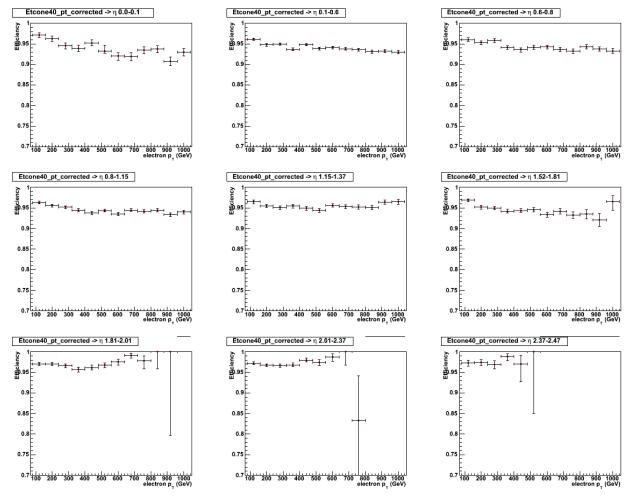
#### Brief look at isolation (1)

- Computed isolation cut efficiencies w.r.t optimised medium ID
  - Considered Etcone40\_pt\_corrected with flat cut : < 10 GeV</li>
  - For more detailled study see <u>Dominick Olivito's talk last week</u>
- Leading electron



#### Brief overview of isolation (2)

Subleading electron



- Subleading always less isolated than leading
  - In agreement with Domick's conclusions

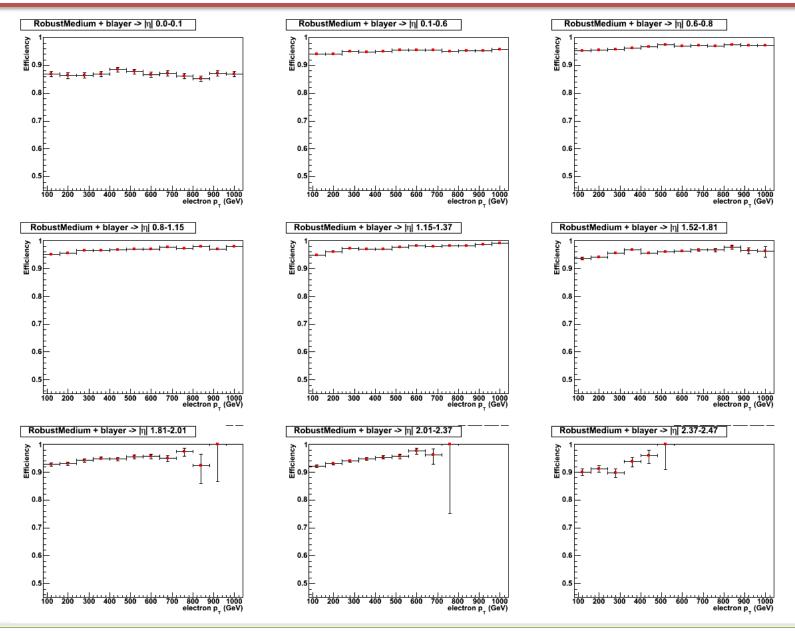
#### Towards optimised Z' cutflow

- Considered adding E/p high cut and isolation to our standard cutflow
  - Avoid bad surprises when looking in detail at our high mass events
- Proposition would be all or part of the followings
  - Medium ID (both electrons)
  - Blayer requirement (both electrons)
  - E/p (both electrons)
  - Isolation (leading electron)
- Computed optimised medium + ... selection efficiency vs pT on leading electron

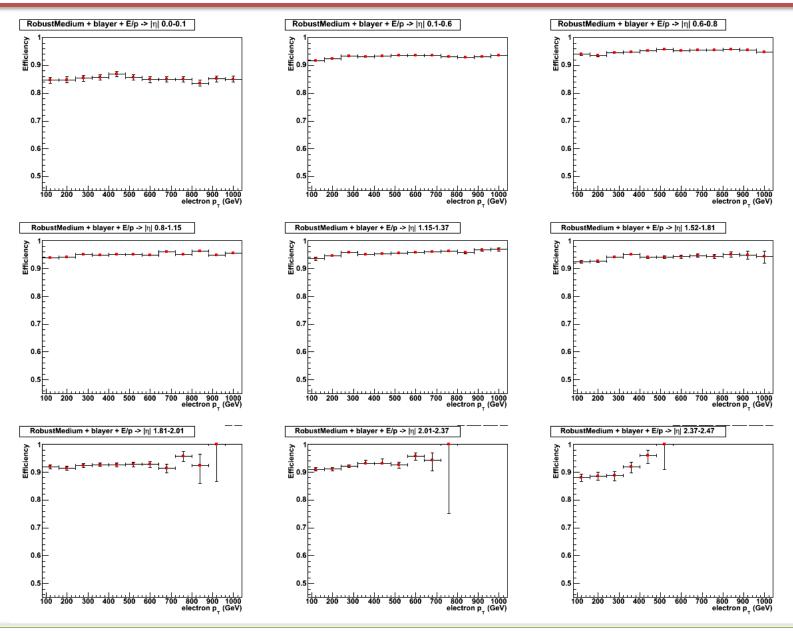
(w.r.t preselection)

- Medium + blayer
- Medium + blayer + E/p
- Medium + blayer + isolation
- Medium + blayer + isolation + E/p

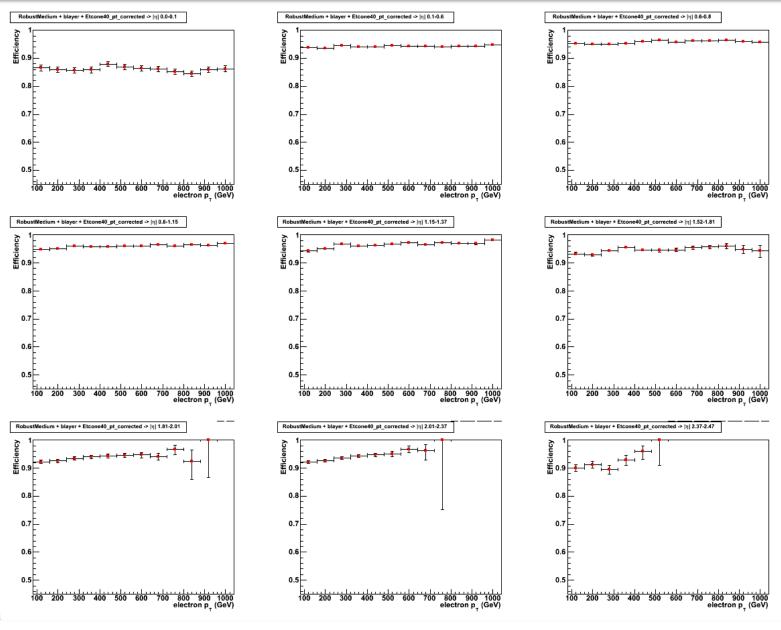
#### Medium + blayer (« standard »)



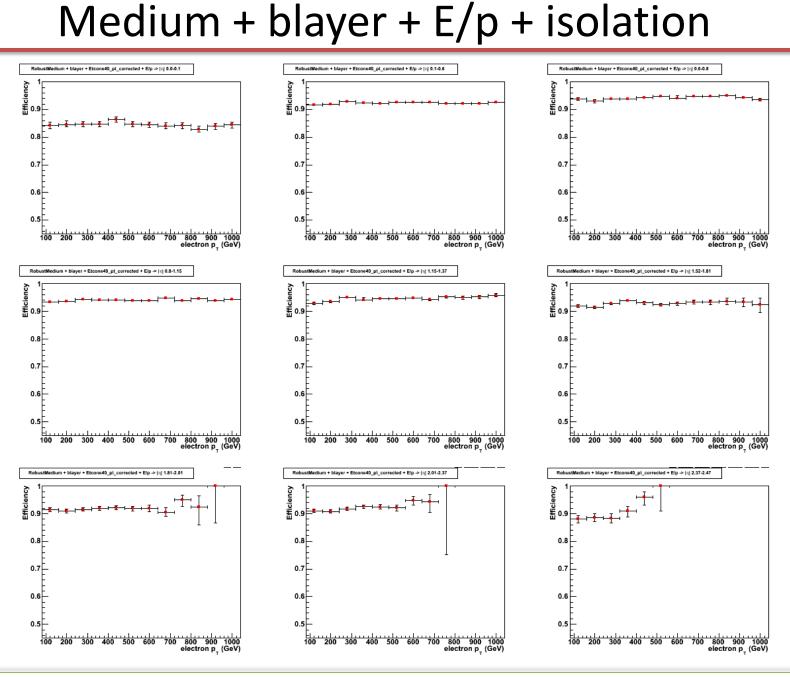
#### Medium + blayer + E/p



#### Medium + blayer + isolation



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### Conclusion

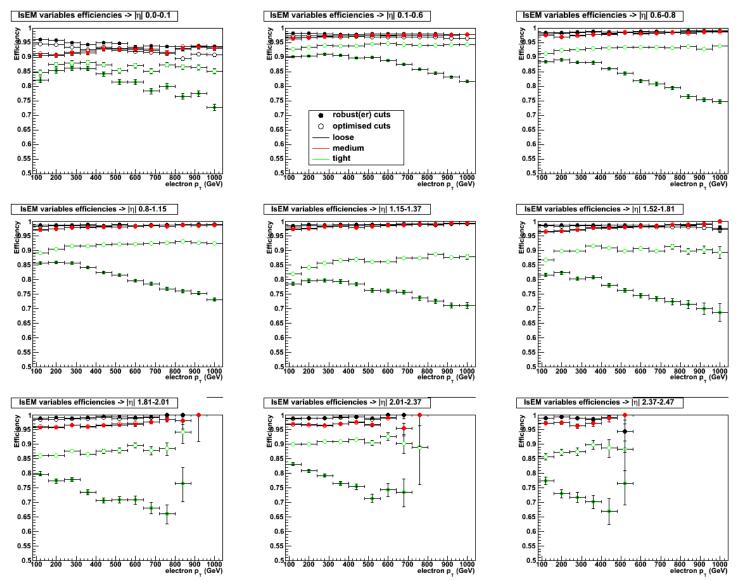
- Updated MC studies on IsEM variables and ID efficiencies with optimised cuts
  - Changes mainly affecting hadronic leakage and E/p
  - Medium efficiency extrapolation at high pT not affected as overall efficiency increasing with pT
- Studied E/p selection
  - E/p cuts @ high pTrelaxed in optimised isEM
    - removed lower bound
    - relaxed upper bound
  - Proposed a rough optimisation of upper bound
    - Efficiency : ~98%
    - Stable behaviour vs pT
- Proposal for optimised cutflows -> E/p ; isolation
  - Adding them separately our together achieve similar performance regarding signal
  - Cost in term of efficiency not that high
  - Could avoid some bad surprises

#### BACKUP

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#### IsEM ID efficiencies - robust vs optimised

- IsEM ID efficiencies vs pT w.r.t to previous ID selection
  - Optimised vs robust shows no change concerning medium ID



#### E/p lower bound efficiencies

